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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

Masanobu IGETA, et al.

GROUP: 2812

SERIAL NO: 10/527,642

FILED: March 14, 2005

EXAMINER: LEE, CHEUNG

FOR: METHOD FOR FORMING INSULATING FILM ON SUBSTRATE, METHOD
FOR MANUFACTURING SEMICONDUCTOR DEVICE AND SUBSTRATE-
PROCESSING APPARATUS

SUBMISSION OF SUPPLEMENTAL APPLICATION DATA SHEET

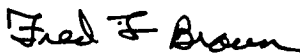
Office of Initial Patent Examination
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Applicant(s) submit herewith a Supplemental Application Data Sheet for the above-identified application for the purpose of correcting the inventors' cities of residence and their mailing addresses.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND,
MAIER & NEUSTADT, P.C.



Steven P. Weihrouch

Registration No. 32,829

Fred L. Braun

Registration No. 56,123

Customer Number

22850

Tel. (703) 413-3000
Fax. (703) 413-2220
(OSMMN 06/04)